

Supporting information

for

**Stimuli-Responsive Circularly Polarized Luminescence with Chiroptical
Amplification and Inversion Enabled by Cholesteric Assembled Bio-materials**

Qing Miao^a, Xi Wang^a, Bowen Jin^a, Yang Chen^a, Yi Zhou^b, Rui Xiong^b, Xiao Meng^{a,*}, Chunhong Ye^{a,*}

a. School of Physical Science and Technology, Shanghai Tech University, Shanghai 201210, China

Email: yechh@shanghaitech.edu.cn, mengxiao@shanghaitech.edu.cn

b. State Key Laboratory of Polymer Materials Engineering, Polymer Research Institute of Sichuan University, Chengdu, 610065 China

Figures

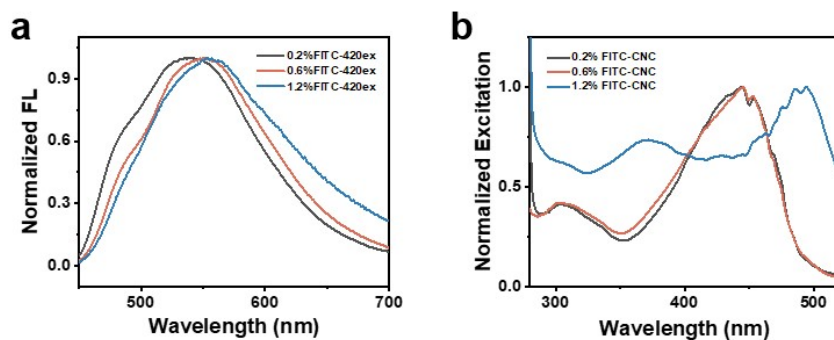


Figure S1. Fluorescence (excitation: 420 nm) and excitation (emission: 550 nm) of CNC-FITC with different concentration.

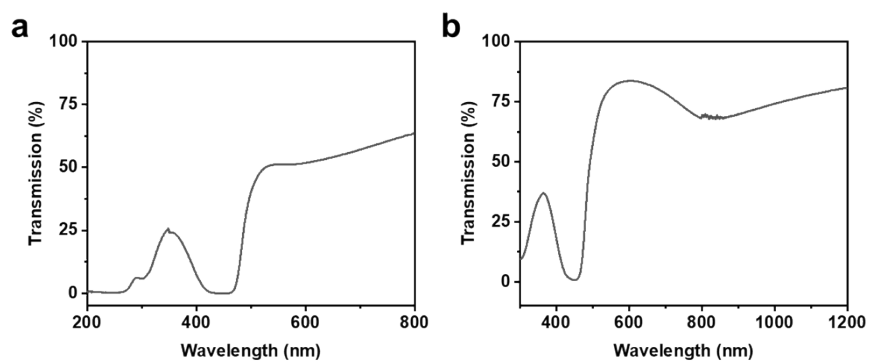


Figure S2. Transmission spectra of CNC-FITC-640 (a) and CNC-FITC-900 (b).

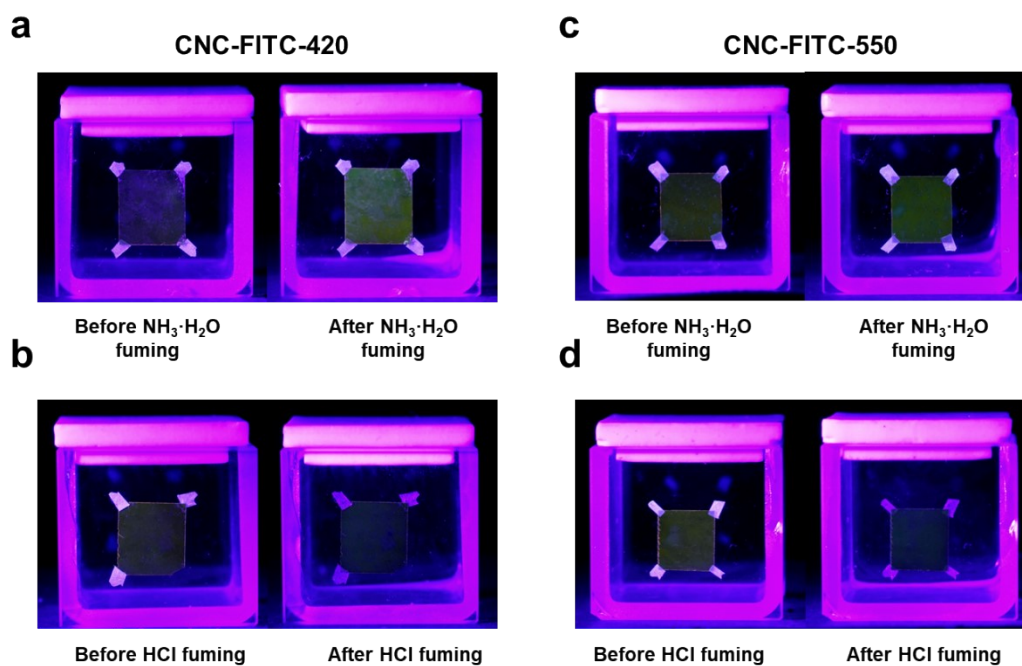


Figure S3. Photographs of the in-situ fluorescence intensity changes of the CNC-FITC- 420 (a, b) and 550 (c,d) under acid and alkaline conditions with UV irradiation.

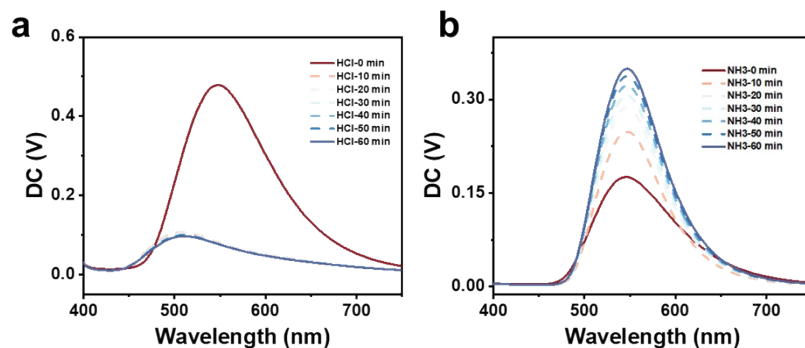


Figure S4. Fluorescence spectra of CNC-FITC-420 under acidic (a) and alkaline (b) vapor fuming.

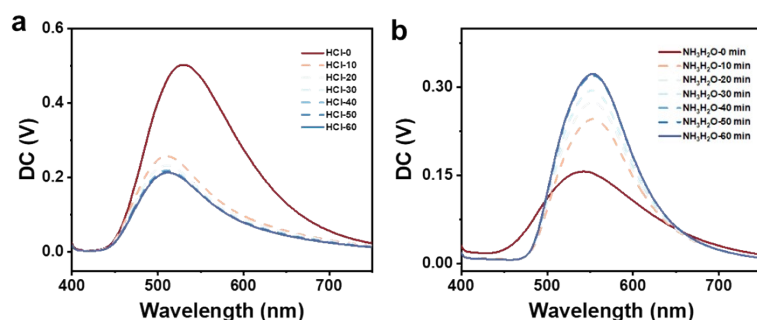


Figure S5. Fluorescence spectra of the CNC-FITC-550 film under acidic (a) and alkaline (b) vapor fuming characterized through CPL spectrophotometer (JASCO CPL-300).

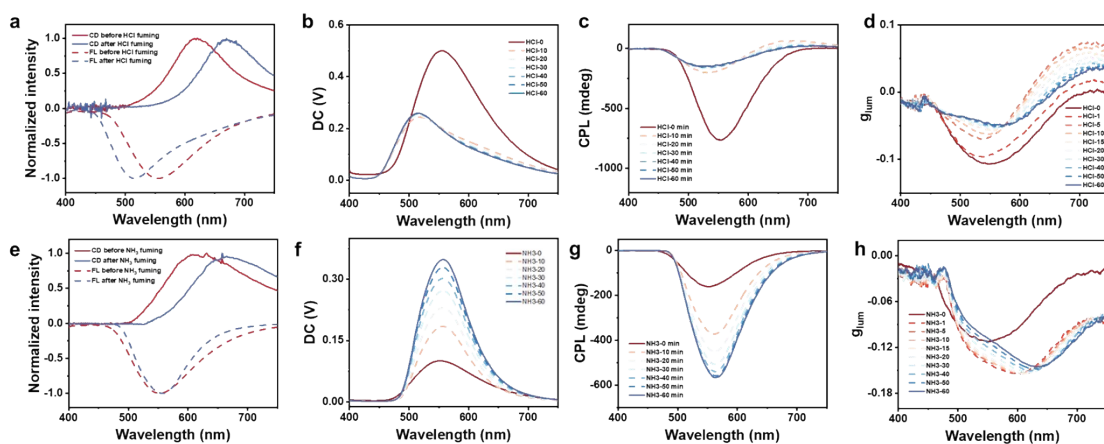


Figure S6. Normalized emission spectra (a), emission spectra (b), CPL (c) and g_{lum} -factor (d) of

CNC-FITC-630 at different time under HCl fuming. Normalized emission spectra (e), emission spectra (f), CPL (g) and g_{lum} -factor (h) of CNC-FITC-630 at different time under $NH_3 \cdot H_2O$ fuming.

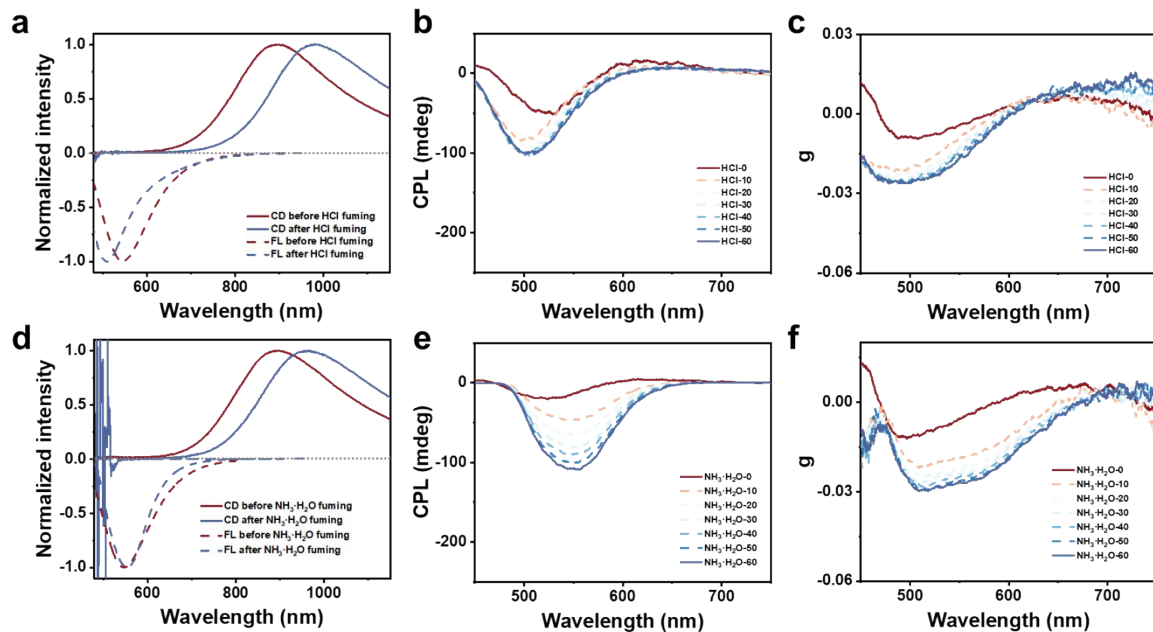


Figure S7. Normalized CD spectra and emission spectra (a), CPL (b) and g_{lum} -factor (c) of CNC-FITC-900 at different treatment intervals under HCl fuming. Normalized CD and emission spectra (d), CPL (e) and g_{lum} -factor (f) of CNC-FITC-900 at different treatment intervals under NH_3 fuming.

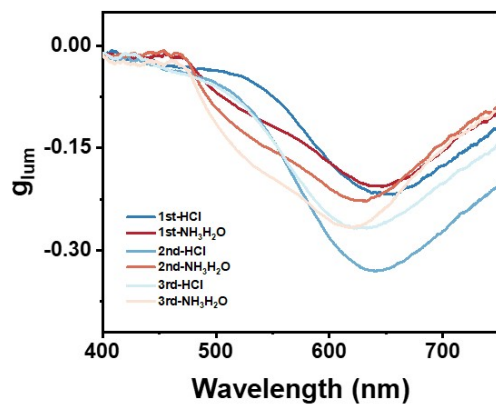


Figure S8. g_{lum} -factor of dynamic CPL switching during cycling tests under acid and alkaline

condition.